



Application Note AN-V-200

Determination of thiourea in copper electrorefining solutions

Precision meets simplicity with the Multi-Mode Electrode pro

In the copper electrorefining process, chemical additives such as thiourea are utilized to enhance electrolytic refining and regulate the grain size of copper deposits. Precise quantification of thiourea is crucial for ensuring the quality of the refined copper. This requires its direct analysis in copper concentrates that contain sulfuric acid and trace amounts of chloride. However, the presence of chloride can interfere with the analysis.

This Application Note introduces a voltammetric method for the accurate quantification of

thiourea in copper electrolytes. The main advantage of this method lies in its ability to precisely determine thiourea levels even in the presence of high chloride concentrations within the sample matrix.

With precise control over thiourea levels, the copper refining process can be adjusted more precisely, leading to improvements in the consistency and quality of the refined copper. This method offers a simple and precise solution for maintaining optimal levels of thiourea.

SAMPLE

Cu electrorefining electrolyte

EXPERIMENTAL

Add the sample and the electrolyte solution into the measuring vessel and degas it for 5 min. The interfering effect of chloride is mitigated through the addition of masking analyte. The determination is carried out using parameters listed in **Table 1**. Quantification is done with the 884 Professional VA manual for MME (**Figure 1**) using two standard additions with thiourea standard addition solutions.



Figure 1. 884 Professional VA manual for MME

Table 1. Parameters

Parameter	Setting
Mode	DME
Start potential	0.3 V
End potential	0.2 V
Sweep rate	2 mV/s
Peak potential Thiourea	-1.45 V

ELECTRODES

- Multi-Mode Electrode pro

RESULTS

Figure 2 presents the result of the determination in an electrorefining solution containing 0.75 mg/L thiourea.

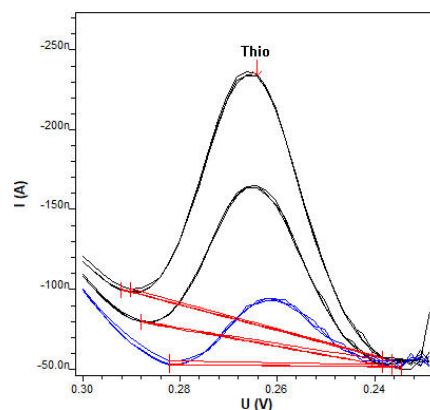


Figure 2. Determination of thiourea in an electrorefining electrolyte containing 0.75 mg/L thiourea

Table 2. Result

Sample	Thiourea in mg/L
Cu electrorefining electrolyte	0.71

Internal references: AW DE4-0164-102004

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CONFIGURATION



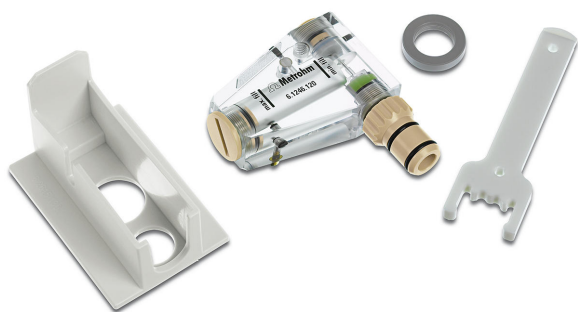
(MME) 884 Professional VA manual

用于多模式电极 (MME) 的 884 Professional VA manual 是借助多模式电极 pro 或 scTRACE Gold 或铋液滴电极使用伏安法和极谱法进行痕量分析的入门仪器。此项已经证实的瑞士万通电极技术与恒电位/恒电位仪以及外接的灵活 viva 软件联用,在重金属测定领域中展现了新的前景。带有经认证的校准器的恒电位仪在每次测量之前均自动冲洗进行校准,确保可能的高精度。

通过此仪器也可使用旋转圆盘电极进行测定,例如借助«循环伏安溶出法»(CVS)、«循环脉冲伏安溶出法»(CPVS)和计时电位法(CP)测定电镀池中的有机添加剂。借助可更换的测量头,可在使用不同电极的各种应用之间实现快速切换。

使用 **viva** 软件进行控制、数据采集和评估。

用于 MME(多模式电极)的 884 Professional VA manual 供货时配备大量附件,包括用于多模式电极 pro 的测量头。电极组和 **viva** 许可证则须单独订购。



Multi-Mode-Electrode pro

用于伏安法的汞电极。可作为 DME、SMDE 或 HMDE 使用。